Reg. No.					



SEVENTH SEMESTER B.Tech. (E & C) DEGREE END SEMESTER EXAMINATION NOV 2017

SUBJECT: MATERIAL SCIENCE for MICRO AND NANOELECTRONICS (ECE - 443)

TIME: 3 HOURS MAX. MARKS: 50

Instructions to candidates

- Answer **ANY FIVE** questions.
- Missing data may be suitably assumed.
- 1A. Indicate and explain with mathematical formulation why some crystal structures are said to be close packed structures?
- 1B. Calculate the number of atoms in 1.4 nm diameter Pt, using bulk density ρ = 21.5 grams / cm³
- 1C. List properties of quantum mechanical wave function.

(4+3+3)

- 2A. Derive an expression and calculate binding energy of lowest orbit of GaAs and InAs. Given that: For GaAs m $_e$ = 0.067 m $_o$ and m $_h$ = 0.45 m $_o$ and ϵ = 12.4 and for InAs : m $_e$ = 0.02 m $_o$ and m $_h$ = 0.4 m $_o$ and ϵ = 14.5 . Comment on the result.
- 2B. Calculate thermal voltage at 300°K, 150°K and 1.5° K. and comment on the result.

(6+4)

- 3A. Calculate the wave function and also energy of first three quantized energy levels for a particle confined in a quantum well of infinite potential walls.
- 3B. How can we define the crystalline, polycrystalline and amorphous materials?

(6+4)

- 4A. Answer all of the following
 - i) The solution for Schrodinger equation for a particle confined in all three dimensions in terms of Energy ------ and wave function ------.
 - ii) The energy levels are quantised while the particle is moving in classically --- region and the wave function is exponentially decay while the particle is moving in classically ---- region.
 - iii) The dispersion relation for an electromagnetic wave travelling in a medium ------
 - iv) Density of energy states is defined as ------
 - v) Buried nanostructures can be characterised by ----- technique.
 - vi) The energy level spacing in metal nano-particles is given by ------
 - vii) Mention the steps for producing high quality Si single crystals.

(2+2+1+1+1+1+2)

- 5A. Explain construction and modes of operation of AFM.
- 5B. Explain how color of a metal nanoparticles differ from that of bulk material.

(5+5)

- 6A. Explain the thin film growth modes in hetero-epitaxial process.
- 6B. Explain steps involved in photolithography technique.
- 6C. Explain what is Bohr radius and exiton Bohr radius and derive relation between them.

(2+5+3)

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